

Czech **Nano** Show 2016

IQ Structures s.r.o.

www.iqstructures.com

Zbynek Ryzi

■ IQ Structures s.r.o.

- start up company founded in **2012** <
- mainly financed by **private** capital of shareholders <
- 2015** - first **profitable** year, revenue about 3 mil. EUR <

■ Business Model

- to add **value** and **functionality** to plastics, metals or ceramics <
- by using **micro-** and **nano-structuring** to modify their properties <
- in order to meet **customer's specific requirements** <

■ Location



- main office** in Technology Park in Řež near Prague <
- nano-center** in Brno <

■ Cooperation Partners

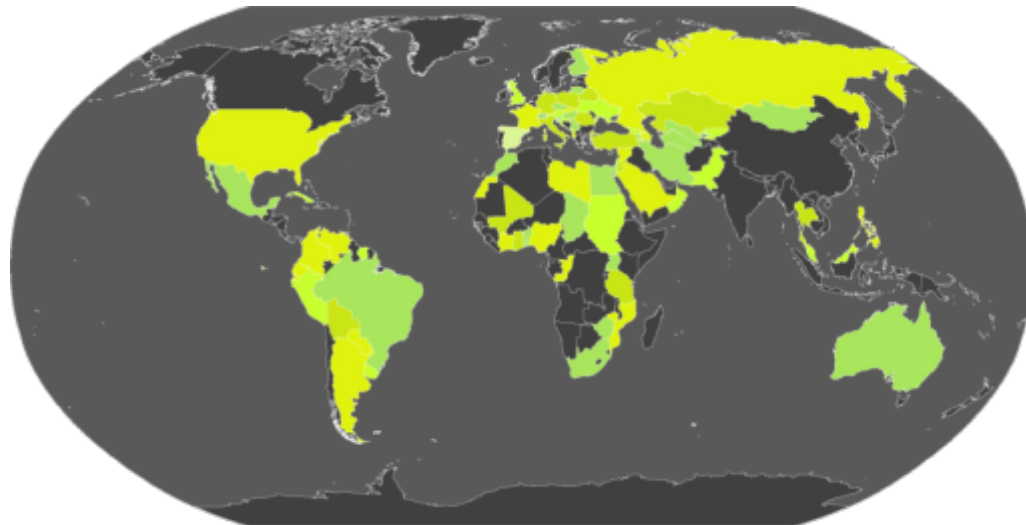
research and development cooperation with the Czech Academy of Science <

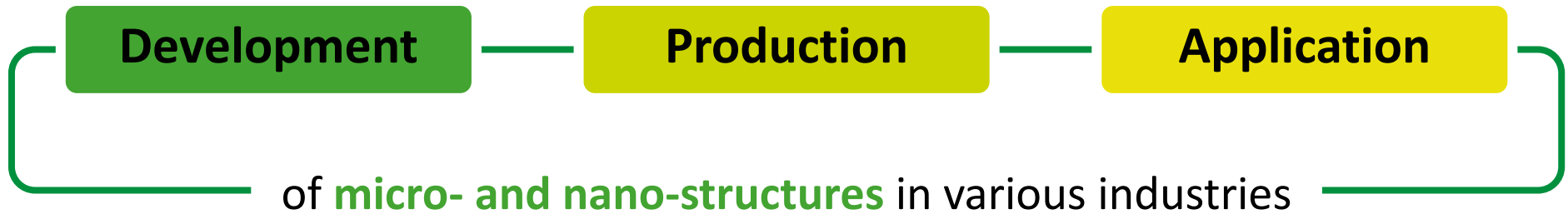
product development cooperation with partners in Europe and USA <

■ Staff

management and team of scientists and engineers with more than 20 years' experience <

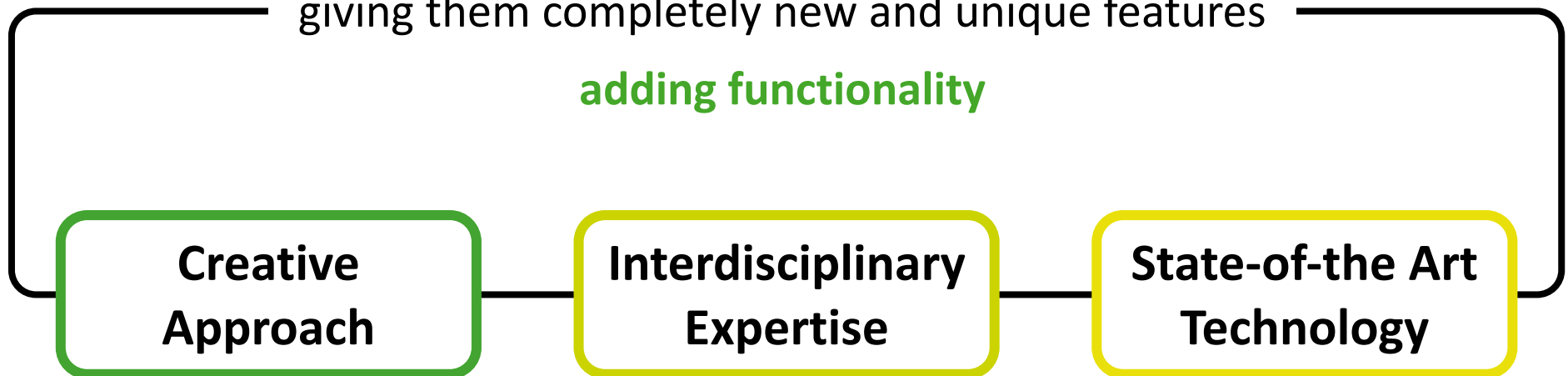
in development, production and delivering products to more than 80 countries
worldwide





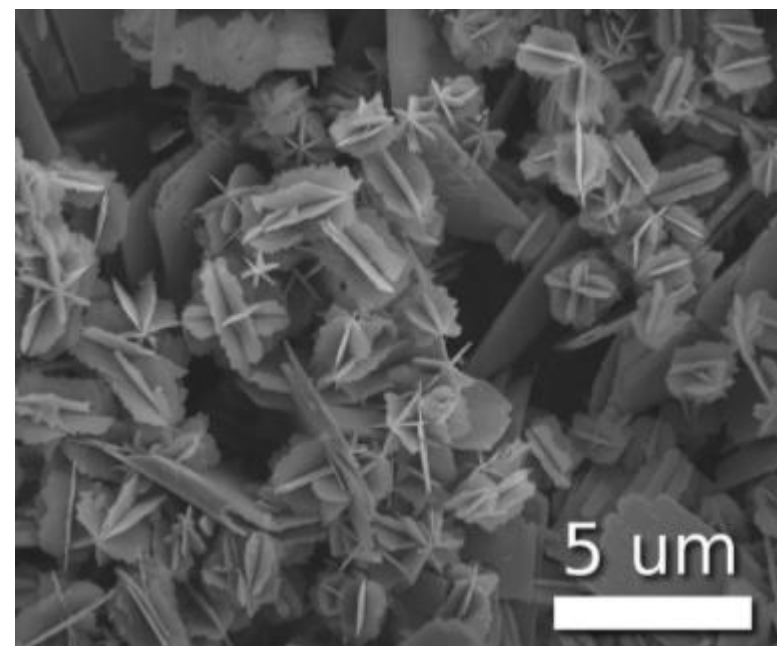
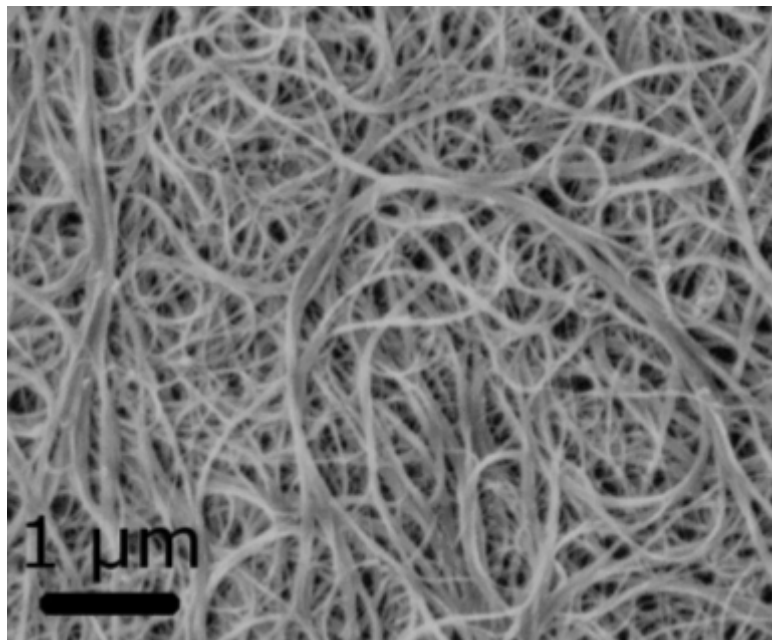
changing the properties of materials or products
giving them completely new and unique features

adding functionality



In the field of nanotechnology we focus on the development of structures **precisely defined** in all three dimensions.

Our expertise is **not** in the production of random or self-organized structures like nanotubes or nanoparticles.

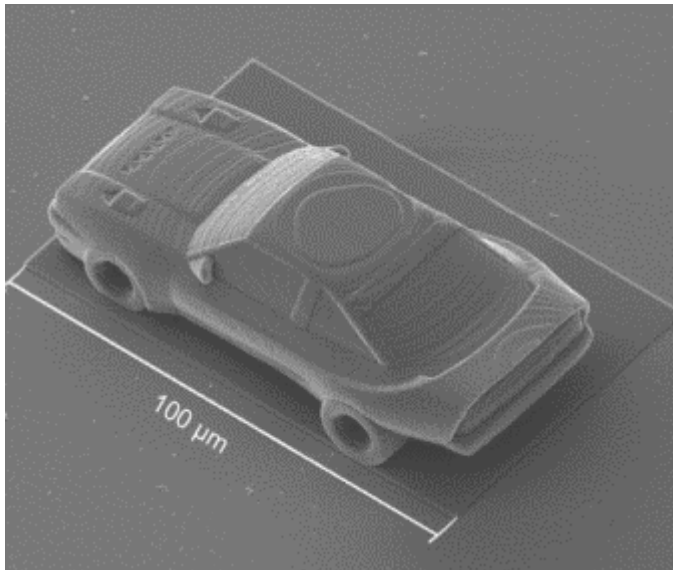


Building on our past experience with 2D structures, we seek to control also the **third dimension** of micro- and nano-structures.

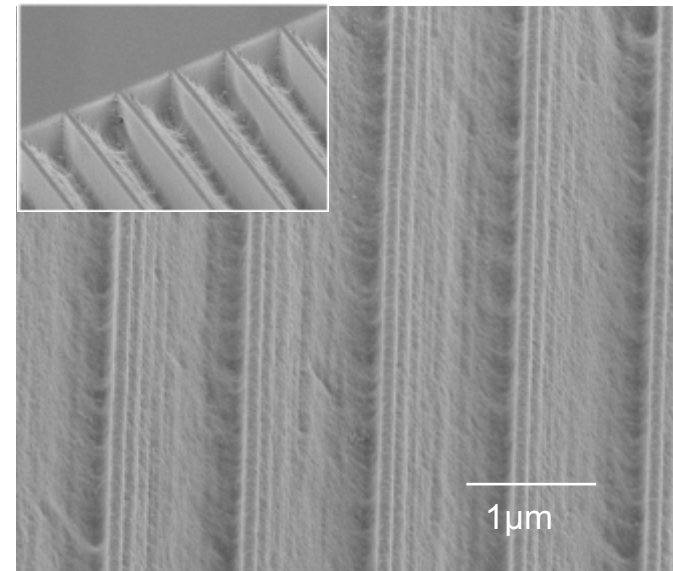
Typical feature sizes of micro- and nano-structures:

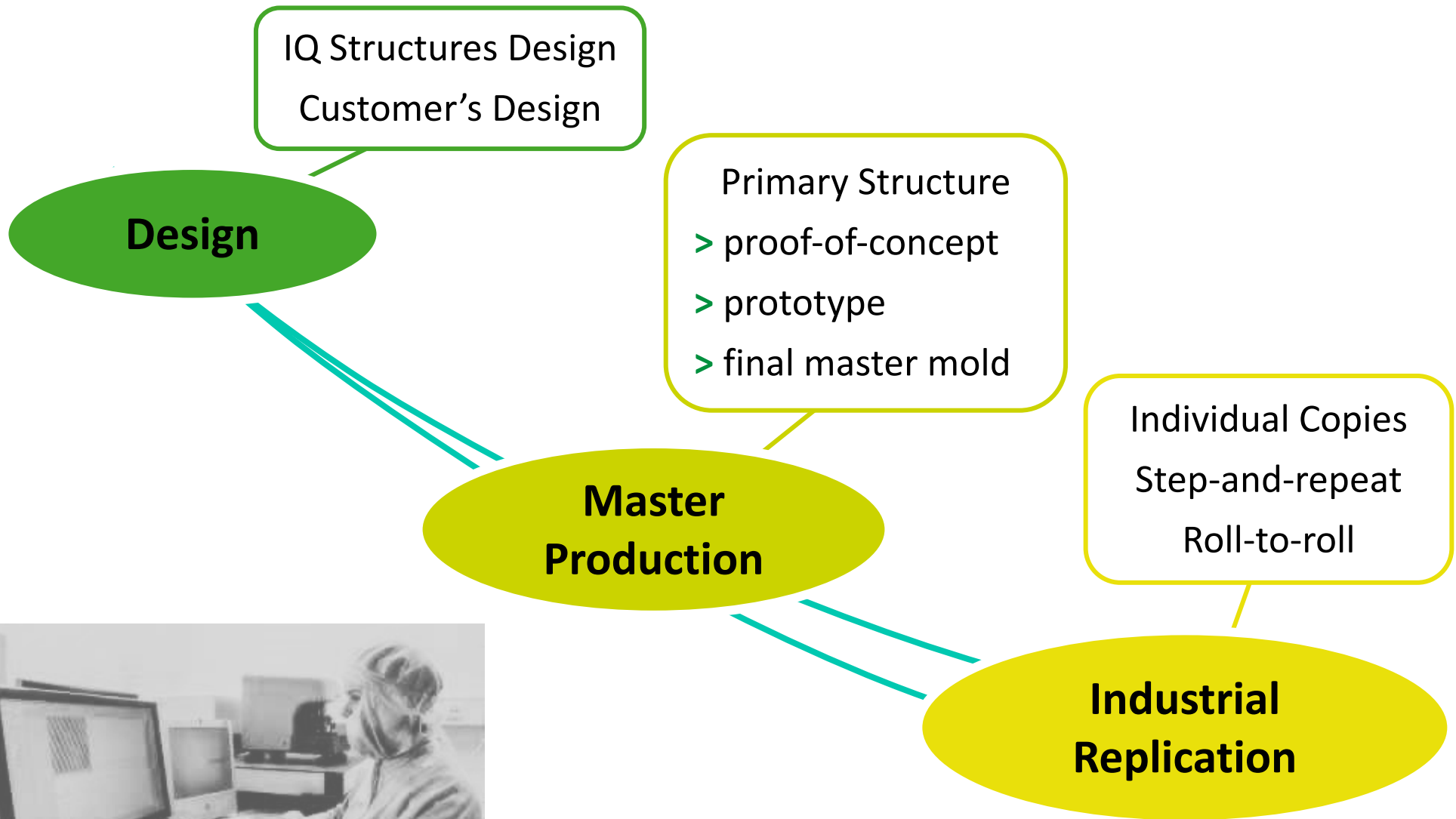
10s of micrometers down to 10s of nanometers

Volume Structures

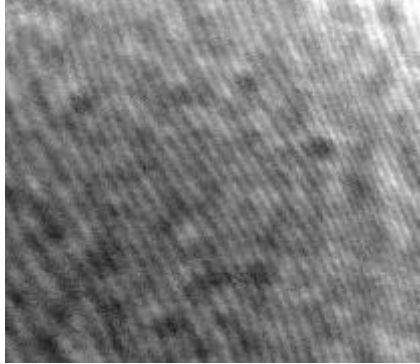


Surface Structures

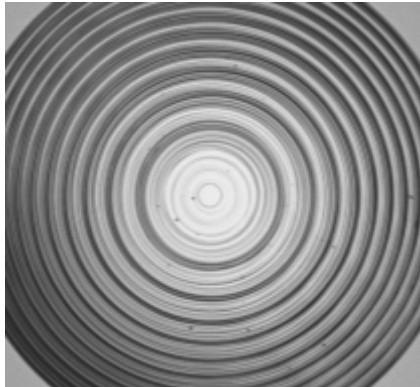




| interference lithography |



| laser lithography |



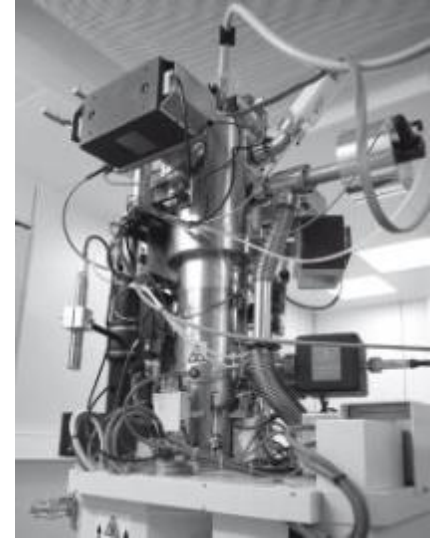
| mechanical engraving |

| UV lithography |

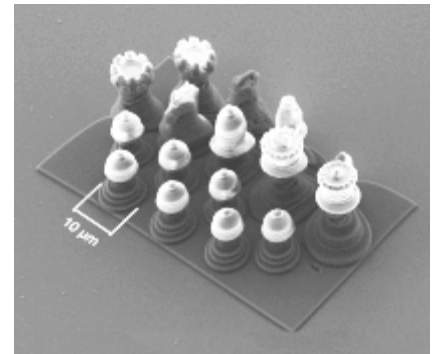
**Master
Production**

| ion etching |

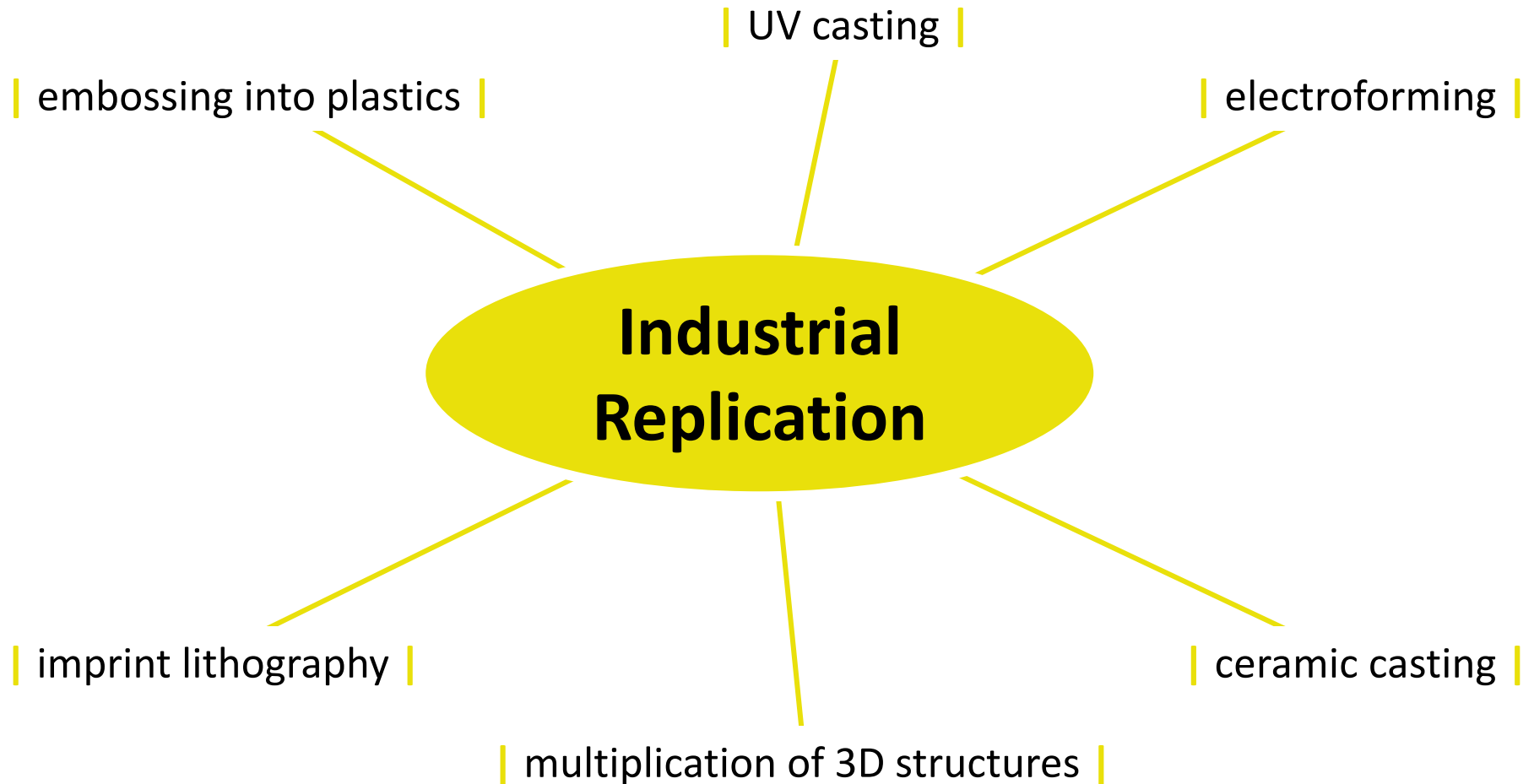
| direct e-beam writing |



| 3D nano-printing |

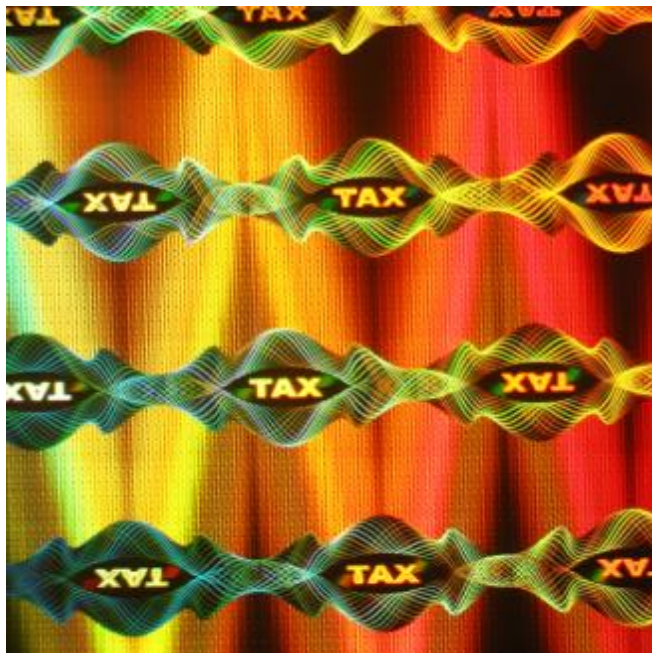
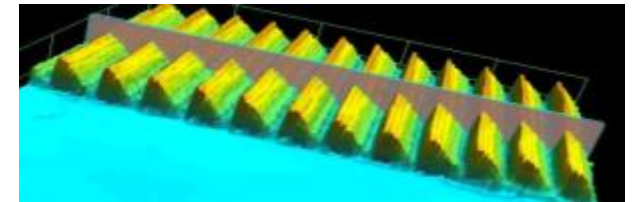


| nano-imprint lithography |



Primary element – **OVID** (optically variable image device)

- > holographic/diffractive image structure
- > covert images – diffractive or micrographical
- > hidden micro- and nano-features
- > micro- and nano-structures formed in various layers (metallic, HRI)



IQ Label – complex combination of OVID structure with other security features

OVID micro- and nano-structure

Inks and Pigments

- > optically variable inks
- > UV, IR, thermoactive inks

Tamper-evident Features

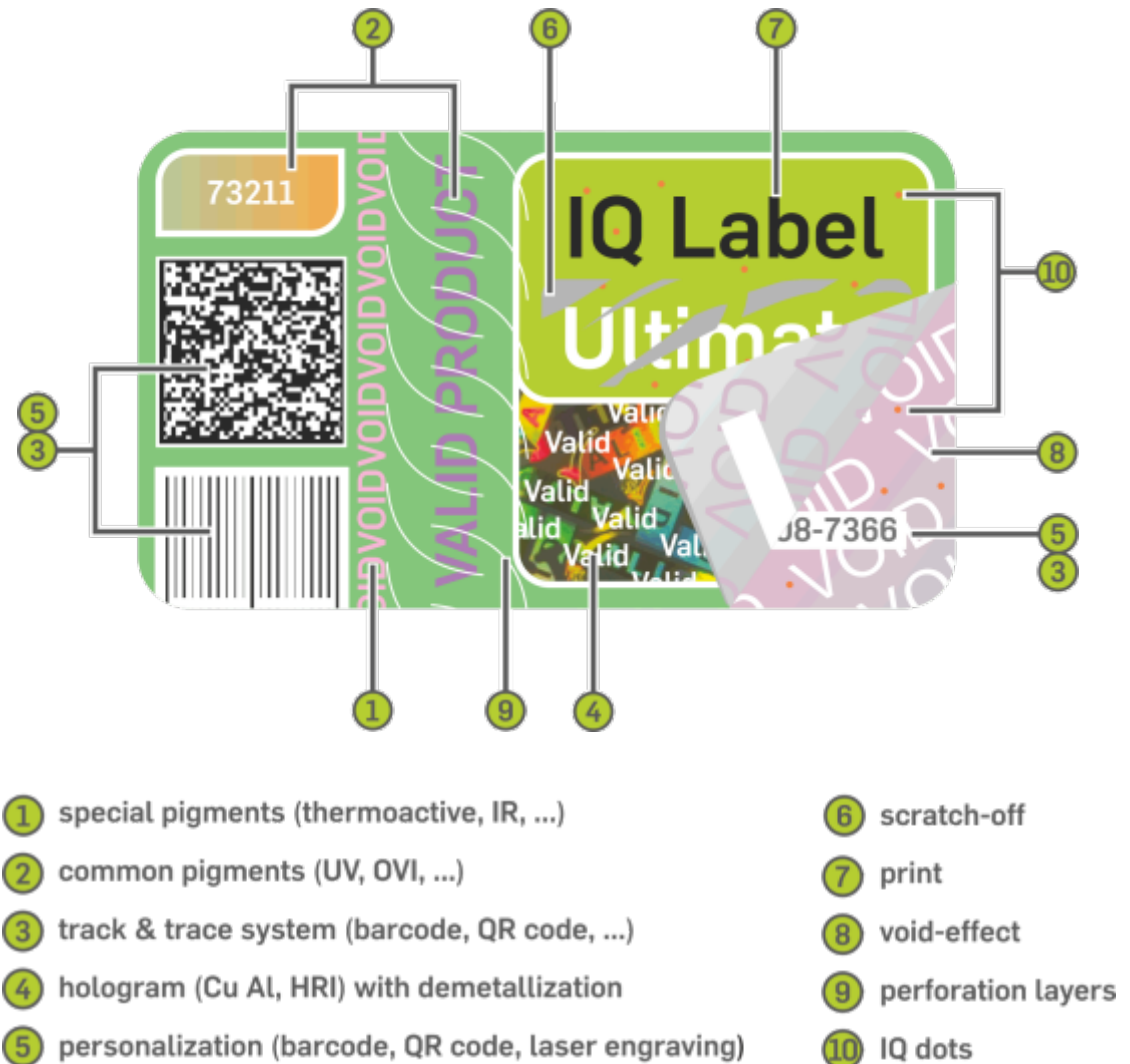
- > perforation layers
- > separation layers

Additives

- > IQ tag
- > IQ dot

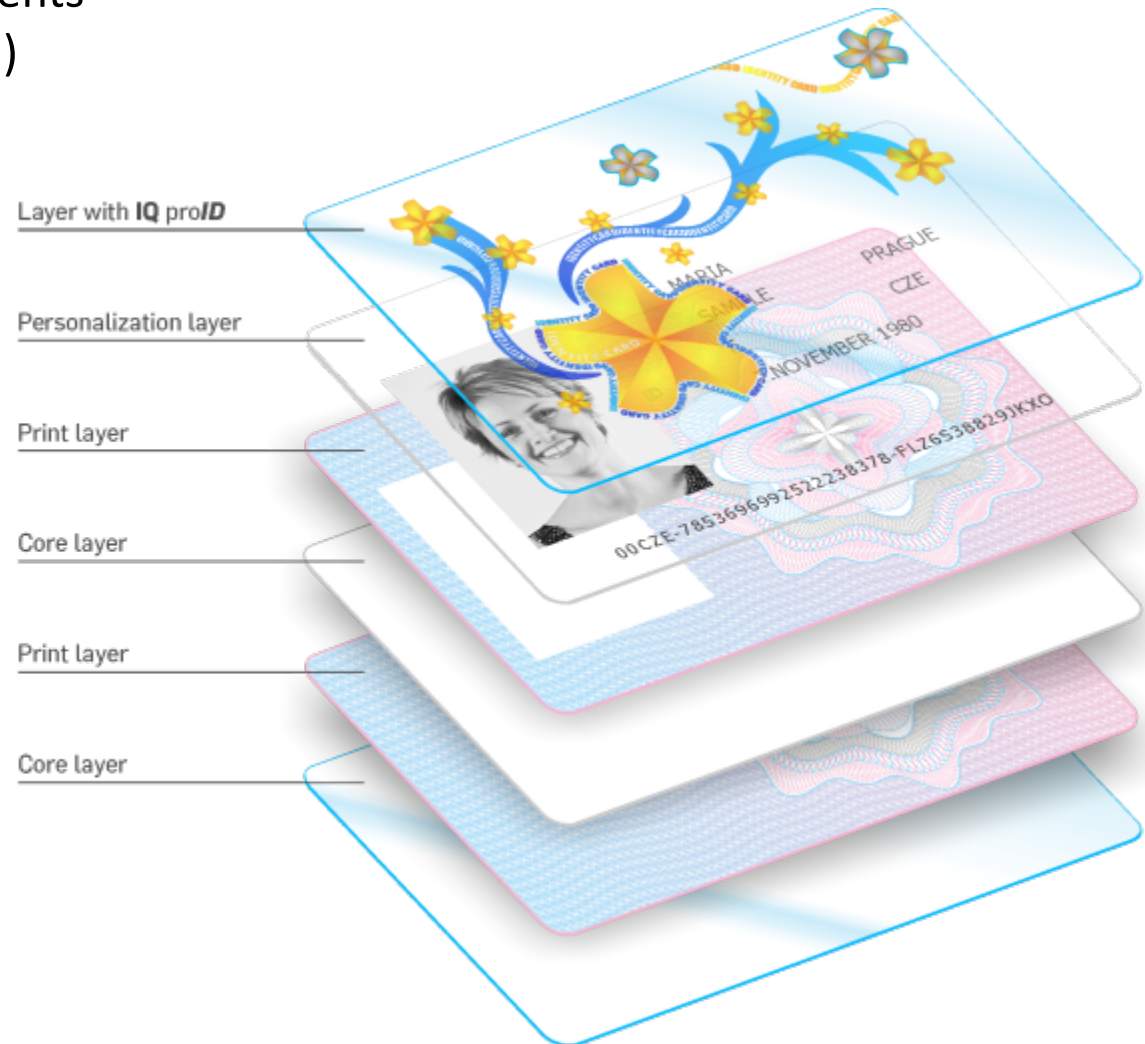
Tracking Features

- > bar code / QR code
- > numbering / personalization

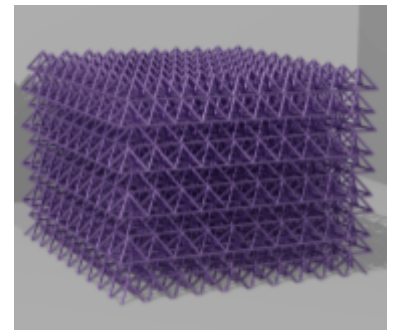


IQ proID designed for protection of polycarbonate based documents

- > primarily for **government** issued documents (passports, ID cards, driving licenses etc.)
- > **full size** coverage
- > **independent** combination of transparent and metallic layers
- > layers can be **personalized**
- > OVID graphics **registered** with printed graphics
- > **proprietary lamination** process to ensure inseparability from other layers (patent pending)
- > supplied in **sheets** or **rolls**
- > **certified** by several partners/customers in US and Europe



- Antireflective, hydrophobic, adhesive structures
- Nano-structured materials – metamaterials
- Tissue and organ replacement
- Micromechanics
- Sensors
- Printed electronic
- Flat optics



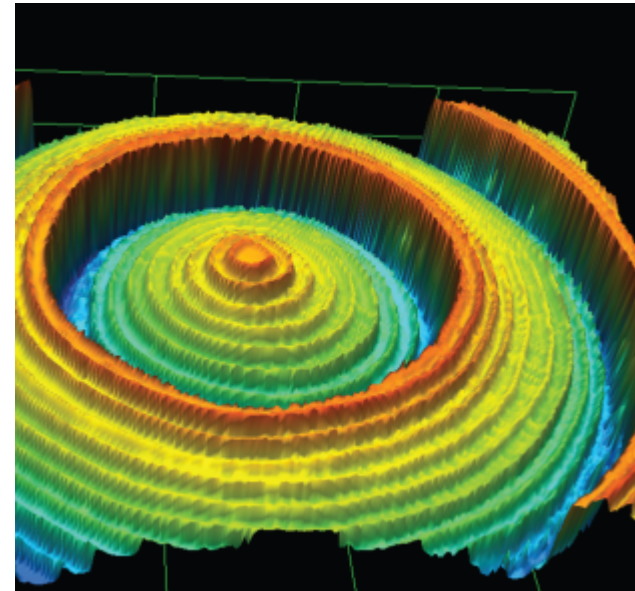
Volume Optics

millimeters

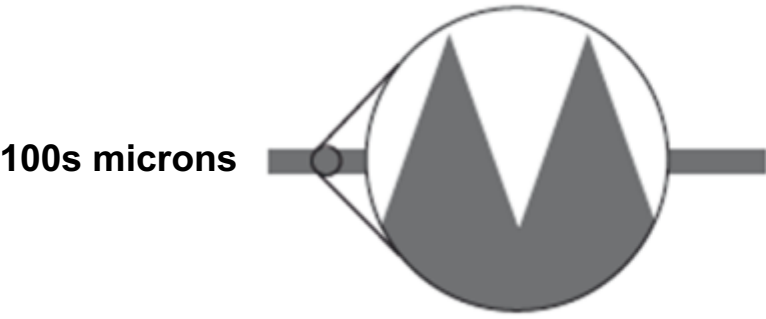


Flat Optics

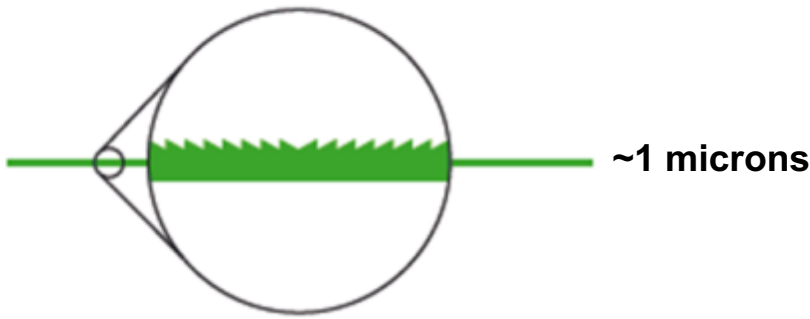
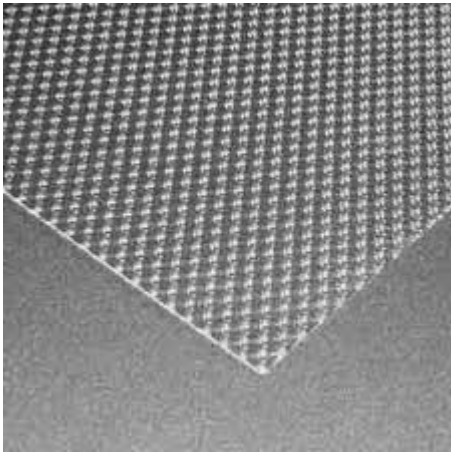
micrometer



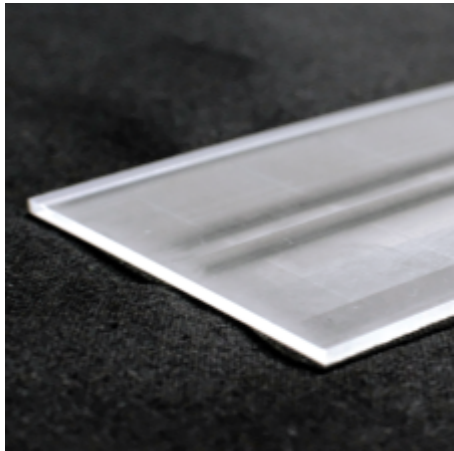
IQ Structures' major development program: flat optics for LED based lights



Volume Structures

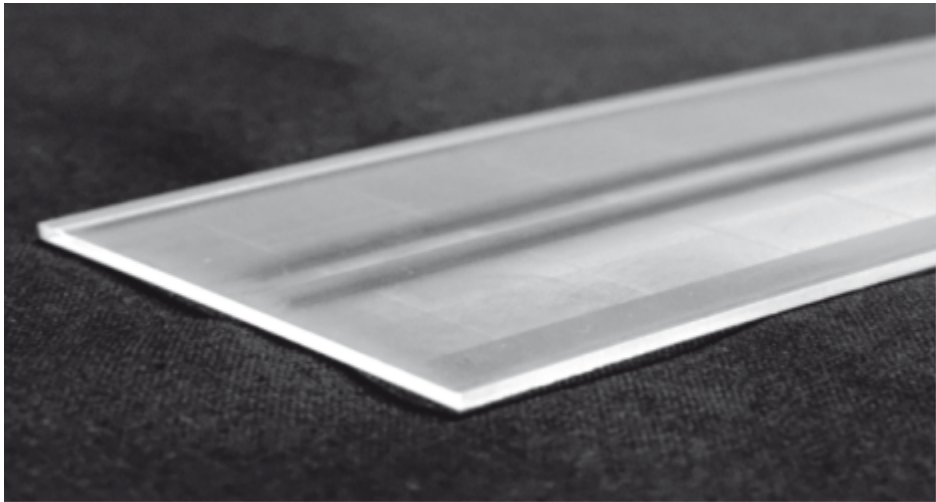


Micro- and nano-structures

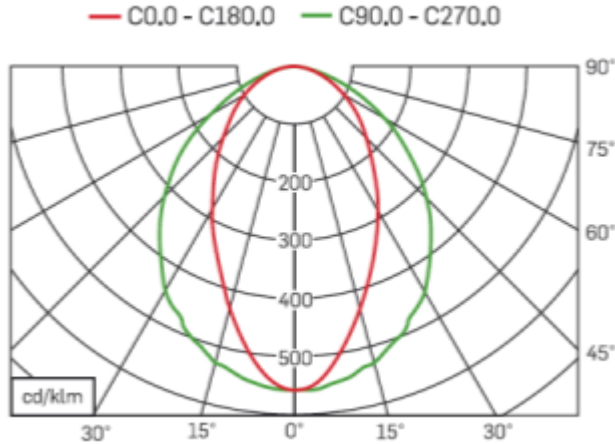
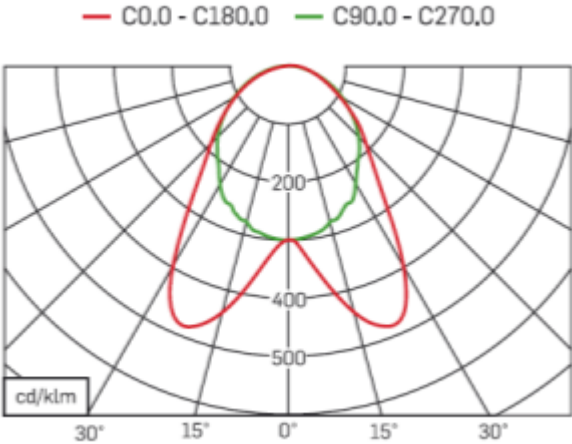
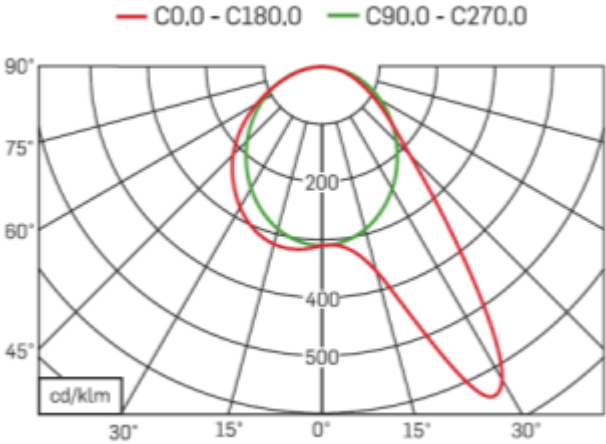


IQ nanoOptics





IQ nanoOptics

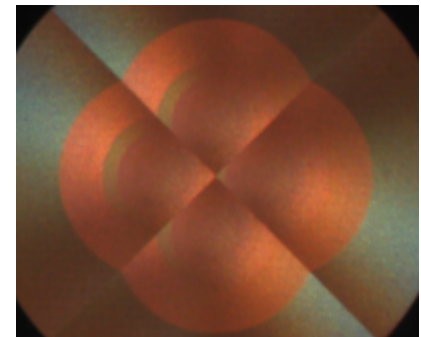
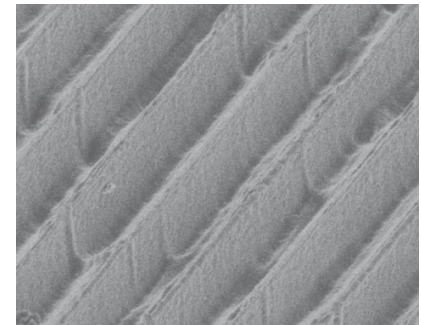


Each **IQ nanoOptics** is custom-designed to meet customer's specific needs

- > Each design of **IQ nanoOptics'** structure is **unique**
- > Design stage of each job includes **simulations** to verify optical performance
- > **Fine-tuning** of the structure's features takes into consideration recording technology constraints
- > Master structure is typically produced by **e-beam lithography**
- > Master structure is replicated on **films** and/or **sheets**

Key Benefits

- > versatility in the design of the optical function
- > reduction in weight
- > highly transparent
- > can be produced efficiently in large volumes



Thank you for your attention.

www.iqstructures.com

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